

X-ray Imaging for Nanoscience: Opportunities and Challenges

NNI Workshop on X-rays and Neutrons:
Essential Tools for Nanoscience

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Opportunities

- Background
 - X-rays are important (R&D spending > \$600M/year and X-ray related business > \$5B/year)
 - Seeing is believing (>\$3B/year market for imaging tools)
 - X-Ray Based Techniques are Powerful structure, chemistry, crystallography, texture, magnetism ----
- Opportunities
 - Nanoscience and nanotechnology requires new tools with a resolution approaching 1 nm
 - X-ray imaging offers powerful and unique capabilities by adding spatial resolving power to well established x-ray techniques



Important parameters of Imaging

- Resolution
- Exposure time
- Desired Information
- Sample requirement

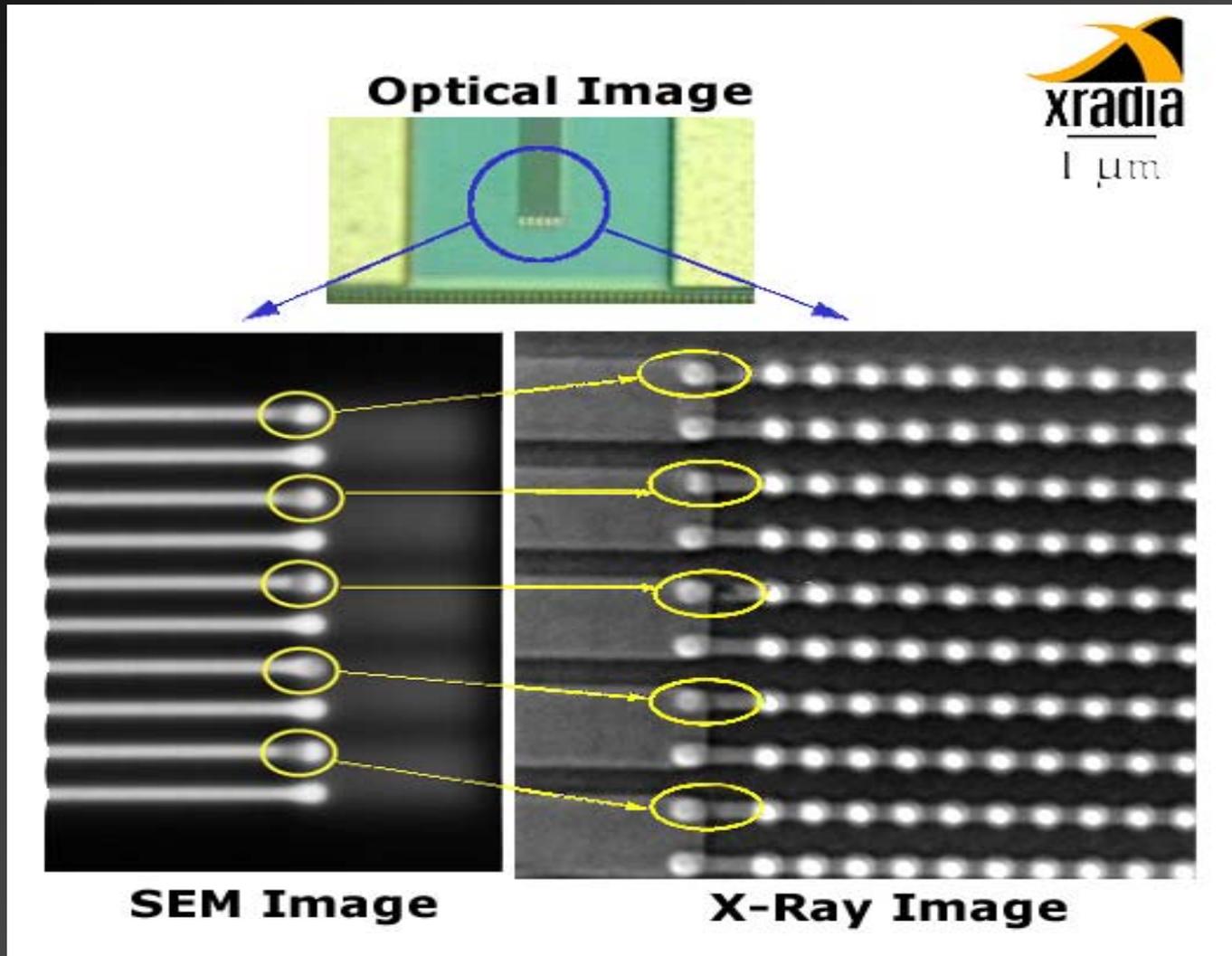
Generation Definition of Imaging?

- Spatial distribution (2D&3D) of specific information about an object, e.g.,
 - Structure
 - Electronic states
 - Chemistry (composition and chemical states)
 - Crystallinity
 - Texture
 - Magnetism
 - Strain
 - -----

Comparison of Imaging Tools

Feature	X-ray	Optical	SEM	TEM
Spatial resolution	Current: 15 -25 nm Ultimate: ~1 nm	200-300 nm	1-10 nm typically >500 nm for elemental analysis	0.1 nm
Information Achievable	Outstanding	Good	OK	Good
Probing depth	1-50 μm for E<10 keV, 20 mm for E=100 keV	<100 nm for metal, Opaque or transparent materials	< 10 nm typically < 3000 nm for element analysis	<100 nm
Material class	Insulator, semiconductor, and conductor	Insulator, semiconductor, and conductor	Conductive path required	Conductive path required
Vacuum requirement	No	No	Yes	Yes

The X-ray Advantages: High resolution+3D information

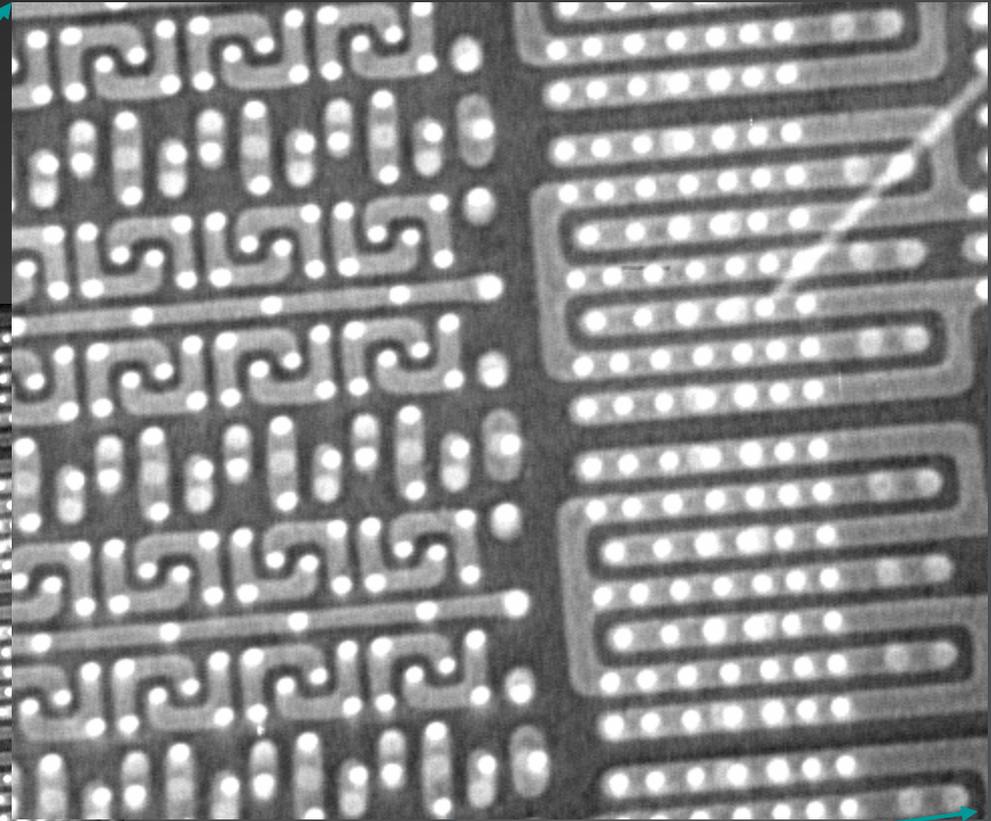
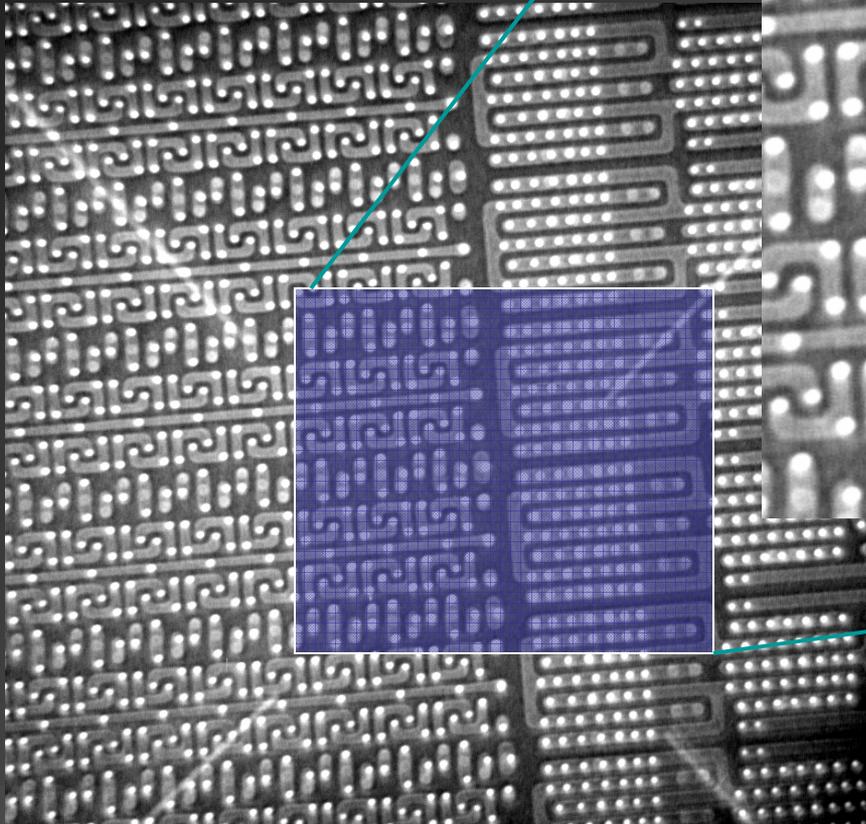


Advantages of X-ray Imaging

- High penetration for nondestructive and in-situ imaging
- Short wavelength for high resolution
- Rich image contrast mechanism: absorption, chemical state, phase, diffraction, polarization
- Element specific: absorption edges and characteristic fluorescence
- No charging effect on image resolution

A X-Ray Image from NanoXCT-60

A latest IC device
deprocessed to M1

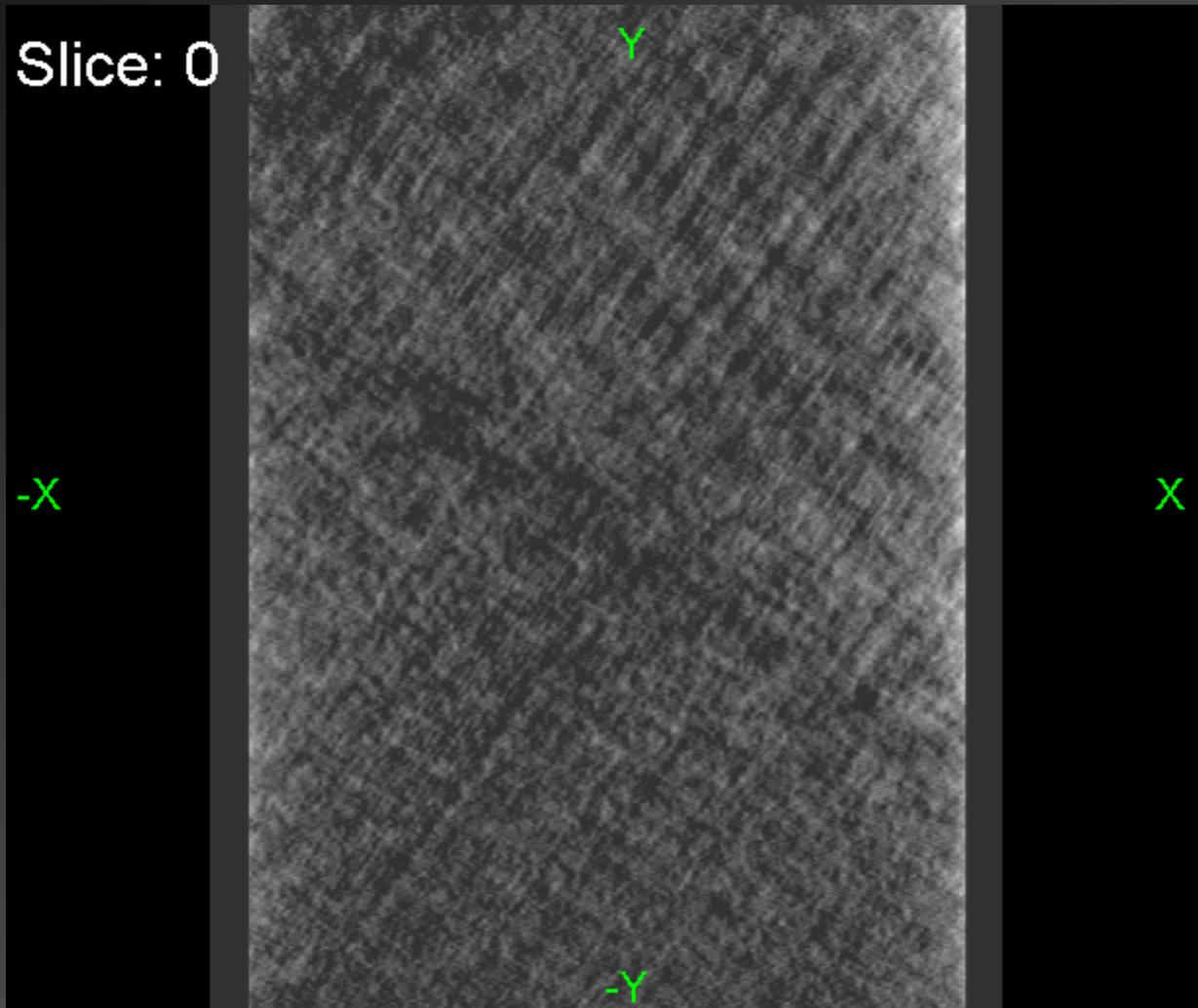


Magnified Image

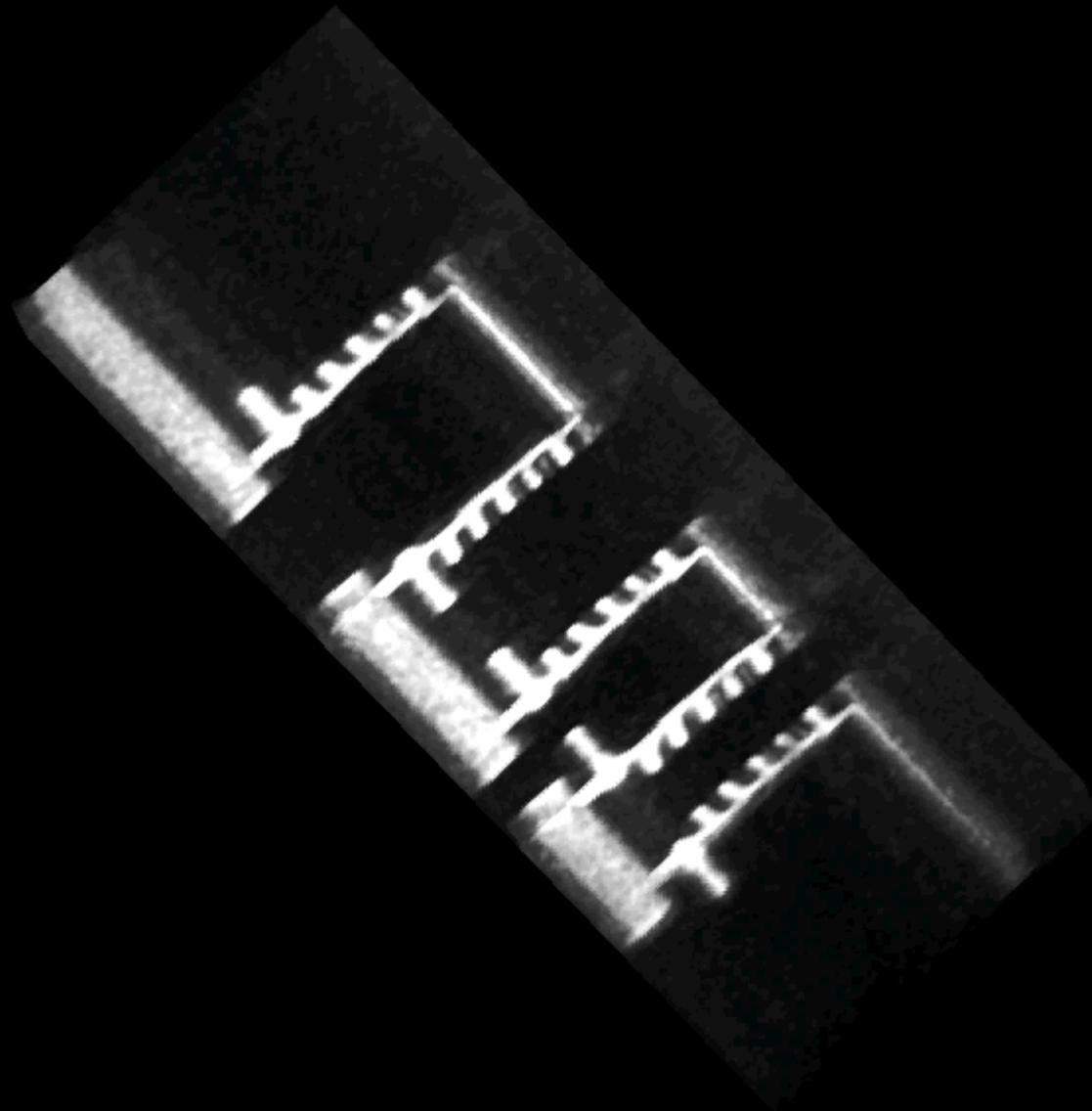
Minim. Feature size: 120 nm
Resolution: < 60 nm



Virtual Slices through the XY Planes of a Reconstructed Tomography Image of an IC Device

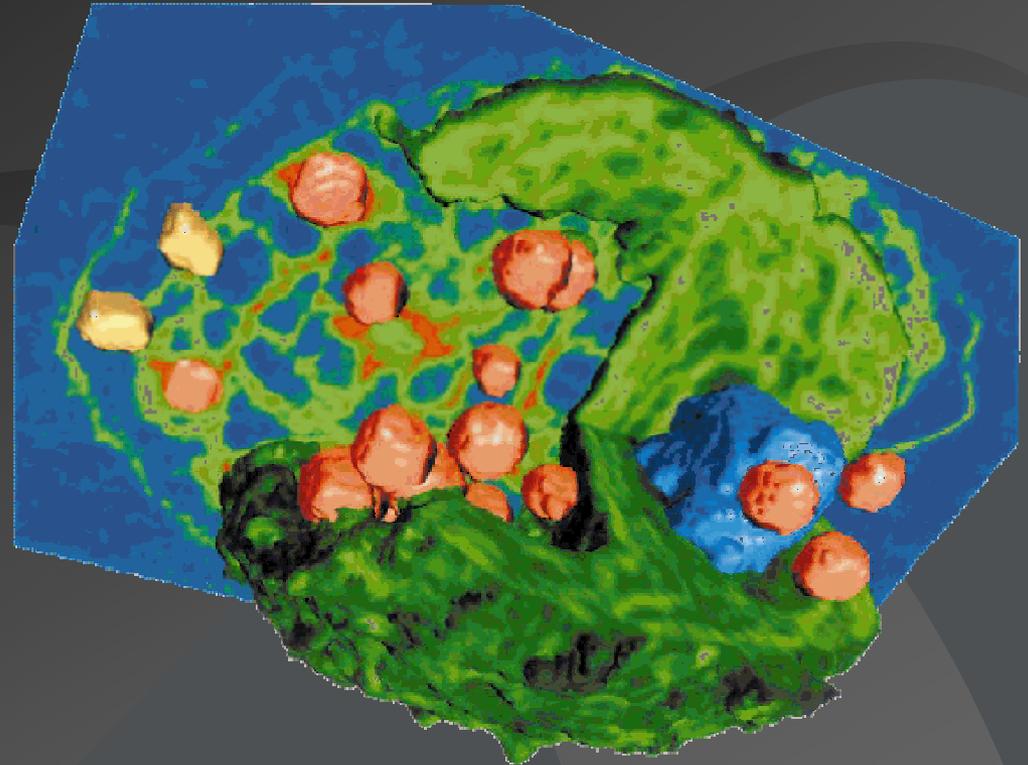


A Rendered 3D Image of a 8-level Cu Device Showing Electromigration Defects



Tomography in a TXM

- TXM is *much* faster for tomography!
- D. Weiß *et al.*, *Ultramicroscopy* **84**, 185 (2000). See also G. Schneider *et al.*, *Surf. Rev. Lett.* **9**, 177 (2002)
- *Chlamydomonas reinhardtii*, frozen in liquid nitrogen.
- Rendering: organelles highlighted by optical density



Requirements and Challenges for X-ray Imaging Microscope with 1 nm Resolution

Requirements for high resolution x-ray imaging

- Adequate image contrast
- Sound methodology: many well established concepts
- Bright source: available, adequate, and improving
- High resolution objective lens: conceptually possible for sub-10 nm but far from reality

Major challenges:

- High resolution objective lens: Tremendous effort is required to produce 1 nm resolution objective lens with an acceptable efficiency
- High NA condenser: generally more challenging to make
- High speed x-ray detector for synchrotron sources
- Tomography: image alignment, imaging system stability, depth of focus
- Cryo?

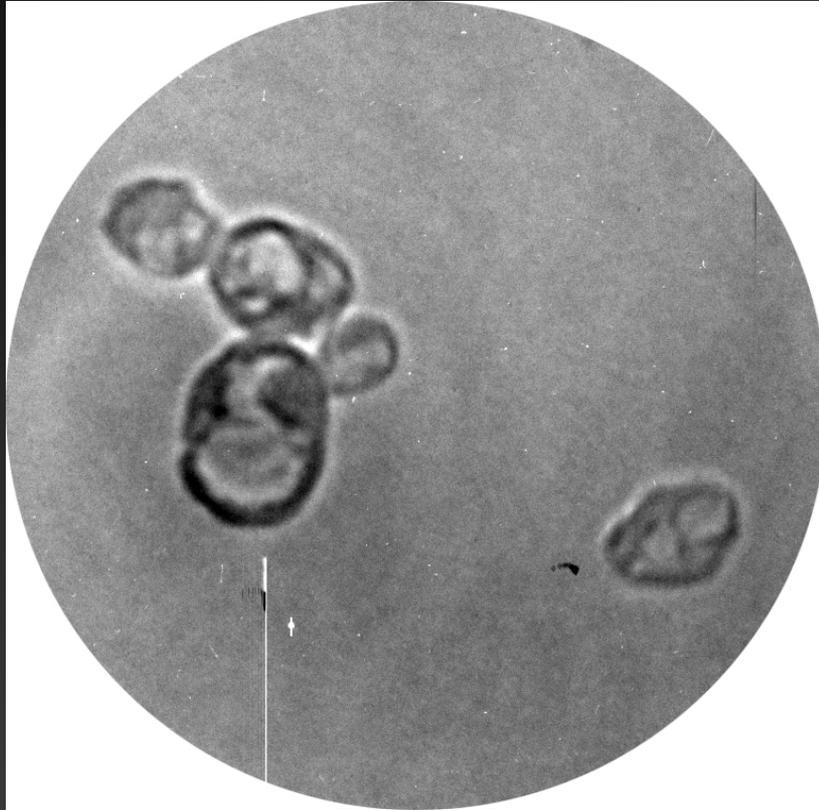


How Small Can be Imaged with X-rays

- Exposure time $T \sim 10/K^2$
K = image contrast $\sim 1/t$, t = thickness of a feature
- Phase image contrast of 1 nm features @1.8keV

Material	Au	Cu	Si
Contrast %	1	0.5	0.1

Phase Contrast Image of Biological Specimens



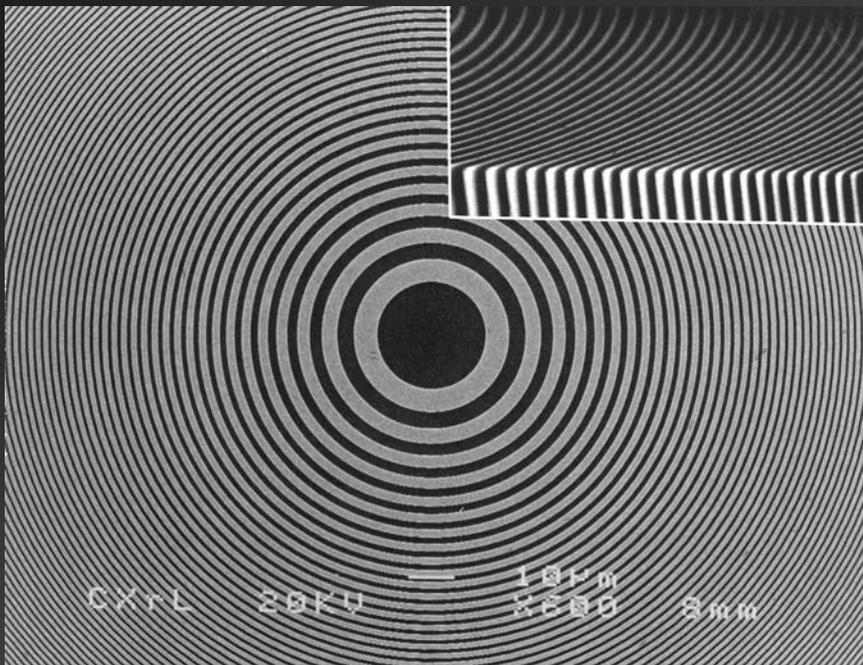
Phase contrast image of yeast cells (a) and 3T3 fibroblast cell (b) using TXM 54-60

Performance Comparison of X-ray Focusing Optics

	KB Mirror	Refractive Lens	Zone Plate
Resolution (nm)	40-60	110	15 for 0.5 keV 25 for 4-20 keV
Flux Density Gain	>500,000	10000	>500,000
Coherence preservation	Acceptable ?	Acceptable?	Good
Imaging Optic	No	Yes	Yes
Chromatic Aberration	No	$1/\lambda^2$	$1/\lambda$
Theoretical resolution limit (nm)	~10	10-20	~1
Mini. focal length for 100 m μ aperture (mm)	~30	100 (?) for 10 keV	0.5 for 0.5 keV 20 for 10 keV

Zone Plate's Key Parameters

Zone plate consists of concentric rings (zones) with zone width decreasing with radius



SEM Image of a ZP and its zone profile

Key parameters:

Number of zones

> 100 required for good focusing

Outermost (smallest) zone width

Determines resolution and NA

Zone materials, thickness, profile

Focusing efficiency

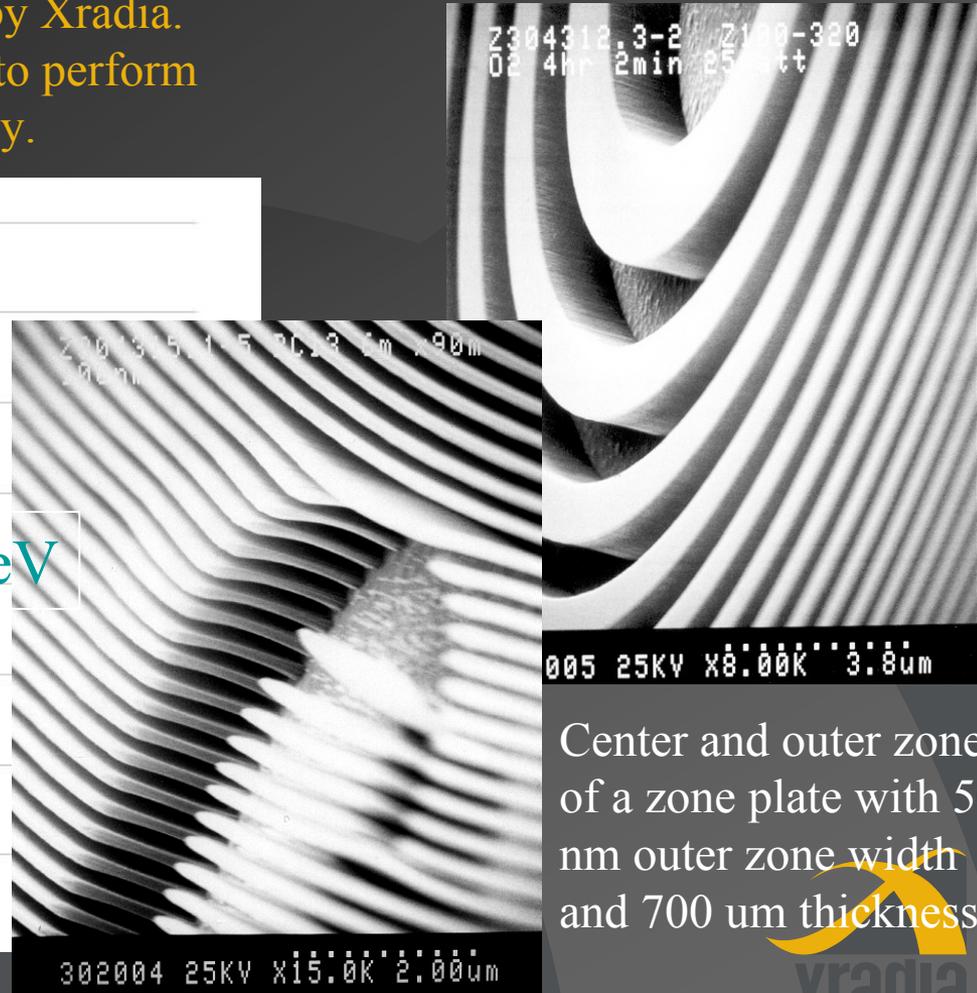
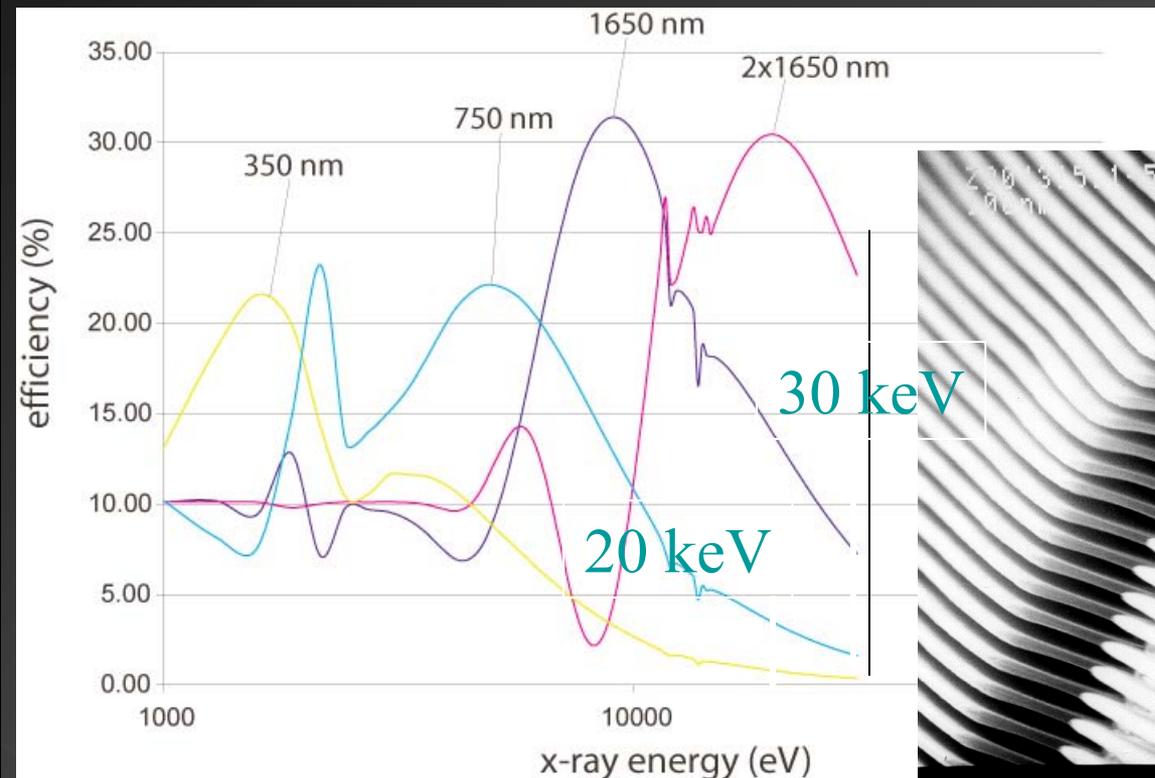
Focal length

Working distance

Zone plates fabricated at Xradia



Theoretical efficiency of zone plates made by Xradia. Zone plates made by Xradia are guaranteed to perform with at least 75% of the theoretical efficiency.



Center and outer zones of a zone plate with 50 nm outer zone width and 700 um thickness.



Xradia's zone plate production capabilities

Energy (eV)	Outermost Zone width (nm)	AR	Efficiency (%)	Diameter (μm)	Material
500	25	6	10	80	Au
1500	35	12	21	80/320	Au
5400*	35	20	17	80/320	Au
9000	50	18	16	100	Au
9000	100	16	31	160/320	Au
9000	100	16	31	4000	Au

Note:

- 1, Xradia warrants >75% of calculated focusing efficiency for its zone plates
- 2, Xradia is currently developing zone plates with finer zones and large diameters,
- 3, Xradia is developing zone plates for 50-100 keV applications



Path to sub 10-nm x-ray imaging

- Improving zone plate fabrication technology
- Using higher order diffraction m

$$\delta = 1.2 \Delta R/m \quad \Delta R = \text{the outermost zone width}$$

$$\begin{aligned} \text{Example: } \delta &= 20 \text{ nm for } \Delta R=50 \text{ and } m = 3 \\ &= 12 \text{ nm for } \Delta R=30 \text{ and } m = 3 \end{aligned}$$

Note:

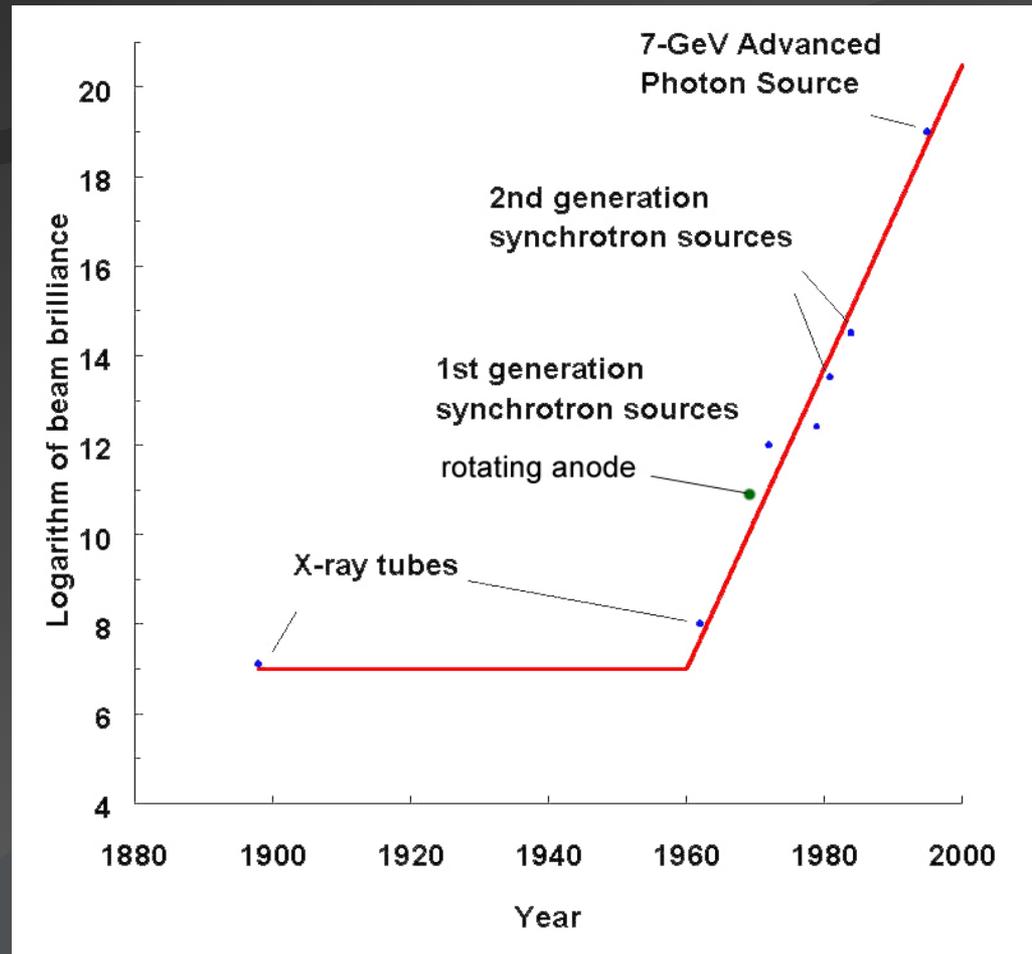
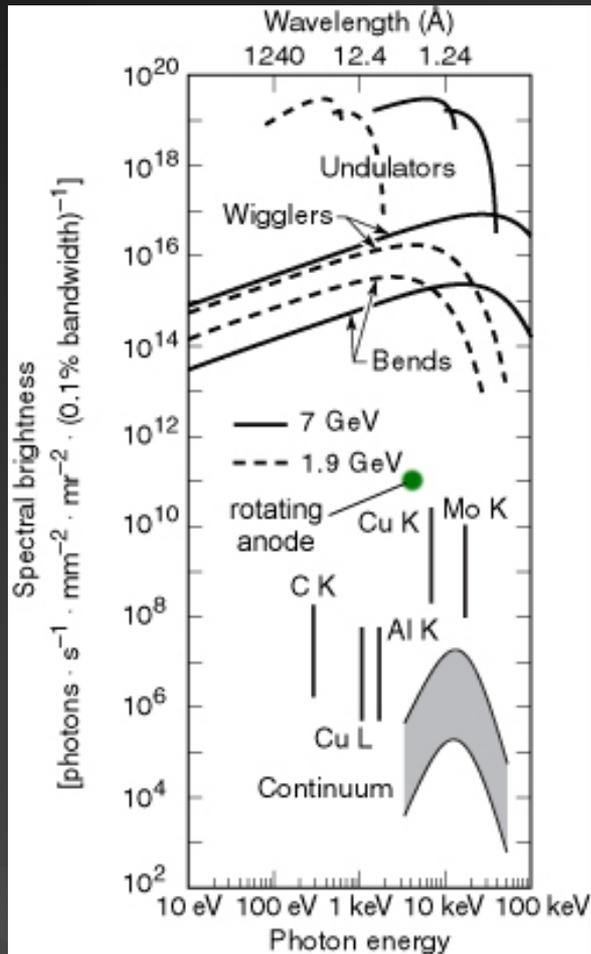
1. $m > 3$ can be used to get better resolution
2. Focusing efficiency $\sim 1/m^2$, acceptable for synchrotron sources



System Components – X-ray Source

X-ray source
of TXM 54-80:

A commercial rotating anode source from Rigaku with Cr anode - 5.4 keV x rays from Cr $K\alpha$ -line.



Summary Remarks

- X-ray imaging offers important and unique characterization capabilities to nanoscience, e.g. in-situ nondestructive 3D imaging
- X-ray microscopy is evolving rapidly in recent years
- ~1nm resolution is achievable in principle but requires substantial development and a lot of investment, recommending collaboration between RD labs. and industry.